

Application of ultrasonic sprayed zirconium oxide dielectric in zinc tin oxide-based thin film transistor

Oluwabi, Abayomi Titilope; Katerski, Atanas; Carlos, Emanuel; Branquinho, Rita; **Mere, Arvo; Krunks, Malle;** Fortunato, Elvira; Pereira, Luis; **Oja Acik, Ilona** Journal of materials chemistry C 2020 / p. 3730-3739 : ill <https://doi.org/10.1039/C9TC05127A> [Journal metrics at Scopus](#) [Article at Scopus](#) [Journal metrics at WOS](#) [Article at WOS](#)

Characterisation of zirconium doped titanium dioxide thin films deposited by chemical spray pyrolysis

Oluwabi, Abayomi Titilope; Oja Acik, Ilona; Krunks, Malle; Mikli, Valdek; Juma, Albert Owino Proceedings of 13th International Conference of Young Scientists on Energy Issues : CYSENI 2016 : May 26-27 2016, Kaunas, Lithuania 2016 / p. VII-210 - VII-218

Combinative solution processing and Li doping approach to develop p-type NiO thin films with enhanced electrical properties

Oluwabi, Abayomi Titilope; Spalatu, Nicolae; Maticiu, Natalia; **Katerski, Atanas; Mere, Arvo; Krunks, Malle; Oja Acik, Ilona** Frontiers in materials 2023 / 12 p. : ill <https://doi.org/10.3389/fmats.2023.1060420>

Effect of Zr doping on the structural and electrical properties of spray deposited TiO₂ thin films

Oluwabi, Abayomi Titilope; Juma, Albert Owino; Oja Acik, Ilona; Mere, Arvo; Krunks, Malle Proceedings of the Estonian Academy of Sciences 2018 / p. 147–157 : ill <https://doi.org/10.3176/proc.2018.2.05> [Journal metrics at Scopus](#) [Article at Scopus](#) [Journal metrics at WOS](#) [Article at WOS](#)

High-K ZrO₂ thin films by chemical spray pyrolysis method [Online resource]

Oluwabi, Abayomi Titilope; Oja Acik, Ilona; Katerski, Atanas; Krunks, Malle Tartu Ülikooli ASTRA projekt PER ASPERA : Funktsionaalsed materjalid ja tehnoloogiad : [7-8 märtsil 2018, Tallinn : teesid] GSFMT Scientific Conference 2018 : Tallinn, March 7-8, 2018 : abstracts 2018 / 1 p <http://fmdtk.ut.ee/teesid-2018/>

High-κ metal oxide thin film by chemical spray pyrolysis : from optimization of material properties to application in thin film transistor = Metallioksiidi õhukesed kiled keemilise pihustuspürolüüsi meetodil : materjali omaduste optimeerimine ja rakendamine õhukesekilelistes transistorides

Oluwabi, Abayomi Titilope 2020 <https://digikogu.taltech.ee/et/Item/4b6d9afd-74d2-40ac-9c12-335d2f608474>
https://www.ester.ee/record=b5362429*est

Influence of post-UV/ozone treatment of ultrasonic-sprayed zirconium oxide dielectric films for a low-temperature oxide thin film transistor

Oluwabi, Abayomi Titilope; Gaspar, Diana; **Katerski, Atanas; Mere, Arvo; Krunks, Malle;** Pereira, Luis; **Oja Acik, Ilona** Materials 2020 / art. 6, 14 p. : ill <https://doi.org/10.3390/ma13010006> [Journal metrics at Scopus](#) [Article at Scopus](#) [Journal metrics at WOS](#) [Article at WOS](#)

Solution processed high-K oxides for application as gate dielectric layer in thin film transistor

Oluwabi, Abayomi Titilope; Katerski, Atanas; Mere, Arvo; Krunks, Malle; Oja Acik, Ilona GSFMT Scientific Conference 2020 : Tallinn, February 4-5, 2020 : abstracts 2020 / p. 67 : ill <http://fmdtk.ut.ee/wp-content/uploads/2020/01/GSFMT2020.p>

Structural and electrical characterisation of high-k ZrO₂ thin films deposited by chemical spray pyrolysis method

Oluwabi, Abayomi Titilope; Acik, Ilona Oja; Katerski, Atanas; Mere, Arvo; Krunks, Malle Thin Solid Films 2018 / p. 129 - 136
<https://doi.org/10.1016/j.tsf.2018.07.035> [Journal metrics at Scopus](#) [Article at Scopus](#) [Journal metrics at WOS](#) [Article at WOS](#)

Zirconium doped TiO₂ thin films deposited by chemical spray pyrolysis

Juma, Albert Owino; Oja Acik, Ilona; Oluwabi, Abayomi Titilope; Mere, Arvo; Mikli, Valdek; Danilson, Mati; Krunks, Malle Applied surface science 2016 / p. 539-545 : ill <http://dx.doi.org/10.1016/j.apsusc.2016.06.093>